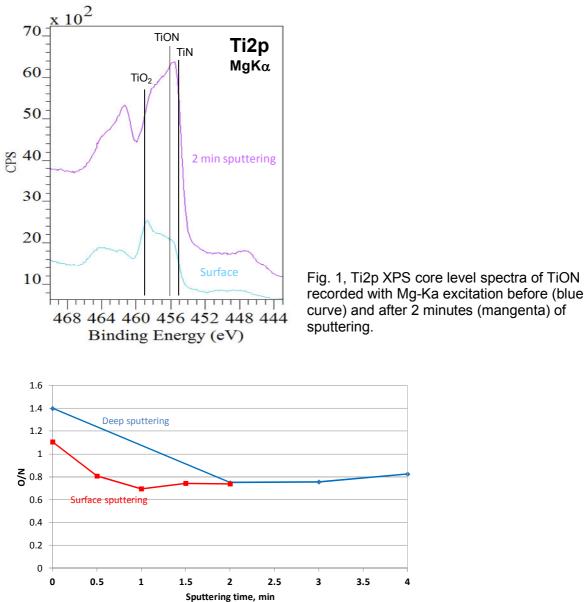
Surface oxidation of titanium oxynitride films prepared by PEALD

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curve) and after 2 minutes (mangenta) of sputtering.

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Fig. 2, O/N ratio of the TiON film versus the sputtering time as determined by XPS. The sputtering was performed with time steps of 1 minute (blue curve with diamonds) and 30 sec (red, reactangles).